

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	("5994226").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 10:59
L2	249	(resist mask\$3) with (carbon C) with (sulfur (sulfur adj dioxide) ("SO.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:31
L3	175	2 and @ad<="20020412"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:02
L4	3	438/689.ccls. and (resist photoresist mask\$3) with (carbon C) with (sulfur (sulfur adj dioxide) ("SO.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:30
L5	3	438/694-696.ccls. and (resist photoresist mask\$3) with (carbon C) with (sulfur (sulfur adj dioxide) ("SO.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:24
L6	6	438/706,734,736.ccls. and (resist photoresist mask\$3) with (carbon C) with (sulfur (sulfur adj dioxide) ("SO.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:25
L7	5	438/725,735.ccls. and (resist photoresist mask\$3) with (carbon C) with (sulfur (sulfur adj dioxide) ("SO.sub.2"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:25
L8	3	("6716758").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:30
L9	2	(resist mask\$3) with ((C-S adj bond\$3) (C-S adj reaction)) with (sidewalls side-walls sidewall (side adj wall))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:34

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L10	13	(resist mask\$3) with ((C-S adj bond\$3) (C-S adj reaction))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/17 11:34
S3	2	("6849478").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/16 13:59
S4	5	(resist pattern\$3) with (carbon) with sulfur same (inorganic (silicon adj dioxide) ("SiO ₂ "))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/16 15:16
S5	2	("6187688").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/06/16 15:16
S6	3	("4581101" "5447598" "5804088").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:02
S8	12	438/689.ccls. and expos\$3 with (resist pattern\$3) with (sulfur S (sulfur adj dioxide) "SO ₂ ")	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:25
S10	9	438/689.ccls. and (resist pattern\$3) with (sulfur (sulfur adj dioxide) "SO ₂ ")	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:24
S11	2	438/689.ccls. and (sulfur (sulfur adj dioxide) "SO ₂ ") same (mask mask\$3) same (sidewall side-wall (side near wall))	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:23
S12	22	438/694-696.ccls. and expos\$3 with (resist pattern\$3 mask\$3) with (sulfur S (sulfur adj dioxide) "SO ₂ ")	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:36
S14	29	438/694-696.ccls. and (resist pattern\$3 mask\$3) with (sulfur (sulfur adj dioxide) "SO ₂ ")	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:45
S15	10	("5207868" "5217570" "5236549" "5266157" "5268070" "5277757" "5326431" "5369053" "5391244" "5436205").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/16 16:43
S16	11	438/689.ccls. and (resist pattern\$3 mask\$3) with (sulfur (sulfur adj dioxide) "SO ₂ ")	US-PGPUB; USPAT; USOCR	OR	OFF	2006/06/17 10:55